

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	256	(360/322).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 13:58
L2	43	(360/328).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 13:58
L3	3301	(360/313-328).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 13:58
L4	195	L3 and (liftoff or lift-off) and (mask\$3 or resist or photoresist or photosensitive or photopolymer) and (CMP or (chemical adj mechanical) or polish\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 13:59
S1	2672	(liftoff or lift-off) and (mask\$3 or resist or photoresist or photosensitive or photopolymer) and (CMP or (chemical adj mechanical) or polish\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 13:58
S2	50	(liftoff or lift-off) and (mask\$3 or resist or photoresist or photosensitive or photopolymer) and (CMP or (chemical adj mechanical) or polish\$3)	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 16:54
S3	49	((liftoff or lift-off) and (mask\$3 or resist or photoresist or photosensitive or photopolymer) and (CMP or (chemical adj mechanical) or polish\$3)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 16:55
S4	99	S2 or S3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 16:55
S5	167	(216/40).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 13:57

S6	222	(liftoff or lift-off).clm. and (CMP or (chemical adj mechanical) or polish\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:45
S7	946	(liftoff or lift-off) and (magnetoresistive)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:05
S8	91	(liftoff or lift-off).clm. and (magnetoresistive)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 16:57
S9	15	(liftoff or lift-off).clm. and (CMP or (chemical adj mechanical) or polish\$3) and magnetoresistive	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 14:33
S10	485	(liftoff or lift-off or mask\$3) and (CMP or (chemical adj mechanical).clm. or polish\$3) and magnetoresistive.clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 16:59
S11	44	((liftoff or lift-off or mask\$3) and (CMP or (chemical adj mechanical) or polish\$3) and magnetoresistive).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:00
S12	1	((fence or fencing) and (CMP or (chemical adj mechanical) or polish\$3) and magnetoresistive).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:01
S13	13	((fence or fencing) and (CMP or (chemical adj mechanical) or polish\$3)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:01
S14	80	(liftoff or lift-off).clm. and (CMP or (chemical adj mechanical) or polish\$3).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:22
S15	611	(216/22).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:04

S16	545	(438/690).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:04
S17	2200	(438/692).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:05
S18	436	(216/88).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:05
S19	386	(216/89).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:05
S20	52	(carbon and (MR or magnetoresistive or magnetic) and leads).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:04
S21	6	S20 and (CMP or (chemical adj mechanical) or polish\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:22
S22	52	((carbon or DLC or diamond-like\$7) and (MR or magnetoresistive or magnetic) and leads).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:31
S23	1	("20040027730").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2005/07/13 17:25
S24	258	(360/313).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:44
S25	3287	(360/313-328).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:32

S26	18176	(360/110-130.34).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:33
S27	2293	S26 and (CMP or (chemical adj mechanical) or polish\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:34
S28	396	(S25 or S26) and (CMP or (chemical adj mechanical) or polish\$3) and (carbon or DLC or diamond-like\$7)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:34
S29	74	(S25 or S26) and (CMP or (chemical adj mechanical) or polish\$3) and (carbon or DLC or diamond-like\$7) and (lift-off or liftoff or (lift adj off))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:35
S30	130	(29/603.01).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:44
S31	327	(29/603.07).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:45
S32	402	(29/603.16).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:45
S33	297	(S30 or S31 or S32) and magnetoresistive	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:45
S34	125	S33 and (CMP or (chemical adj mechanical) or polish\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:45
S35	98	S34 and (liftoff or lift-off or mask\$3 or resist or photoresist or photosensitive or photopolymer)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/13 17:46

S36	149	(carbon and (MR or magnetoresistive or magnetic) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:22
S37	2	("5815910").URPN.	USPAT	OR	OFF	2005/07/20 17:17
S38	8	(MR or magnetoresistive or magnetic) and (carbon and (liftoff or lift-off) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:23
S39	3	(magnetoresistive) and (carbon and (liftoff or lift-off) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:26
S40	20	magnetoresistive and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)	JPO	OR	OFF	2005/07/20 17:25
S41	349	(magnetoresistive or magnetic) and (lead\$1 and carbon or DLC or (diamond adj like) or diamond-like) and (liftoff or lift-off) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:30
S42	1	(magnetoresistive or magnetic) and (lead\$1 and carbon or DLC or (diamond adj like) or diamond-like) and (liftoff or lift-off) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)	JPO	OR	OFF	2005/07/20 17:27
S43	4	(magnetoresistive or magnetic) and ((lead\$1 and carbon or DLC or (diamond adj like) or diamond-like) and (liftoff or lift-off) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:31
S44	5	((lead\$1 and carbon or DLC or (diamond adj like) or diamond-like) and (liftoff or lift-off) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:32
S45	15	((carbon or DLC or (diamond adj like) or diamond-like) and (liftoff or lift-off) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:34

S46	339	(magnetic or magnetoresistive) and ((carbon or DLC or (diamond adj like) or diamond-like) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:46
S47	223	(read) and ((carbon or DLC or (diamond adj like) or diamond-like) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:47
S48	1	(read and (lift-off or (lift adj off)) and (carbon or DLC or (diamond adj like) or diamond-like) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 17:46
S49	20	(read and (carbon or DLC or (diamond adj like) or diamond-like) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 18:03
S50	64	(read adj sensor) and (carbon or DLC or (diamond adj like) or diamond-like) and (CMP or (chemical adj mechanical) or polish\$3 or chemical-mechanical)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/20 18:03
S51	2222	(liftoff or lift-off or (lift adj off)) and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3) and (leads or magnetic or magnetoresist\$4 or carbon or fencing)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 14:35
S52	899	(liftoff or lift-off or (lift adj off)) and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3) and (leads or magnetic or magnetoresist\$4 or carbon or fencing).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 14:35
S54	23	((liftoff or lift-off or (lift adj off)) and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3) and (leads or magnetic or magnetoresist\$4 or carbon or fenc\$3)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:05
S55	2	("20020148105").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:03

S56	6	((("6030753") or ("6218056") or ("6274025")).PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:03
S57	13	((liftoff or lift-off or (lift adj off)) and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3) and (magnetic or magnetoresist\$4 or AMR or GMR or MR)).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:05
S58	14	(liftoff or lift-off or (lift adj off)).ti. and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3) and (magnetic or magnetoresist\$4 or AMR or GMR or MR)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:06
S59	26	S57 or S58	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:08
S60	12	(liftoff or lift-off or (lift adj off)) and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3) and (magnetic or magnetoresist\$4 or AMR or GMR or MR)	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 11:51
S62	37	S57 or S58 or S60	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:14
S63	12	(cyrille and marie-claire).in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:19
S64	50	(dill and frederick).in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:16
S65	67	(cherngye and hwang).in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:17

S66	18	(jui-lung and li).in.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:17
S67	1	(leads and carbon and (chemical adj mechanical) and liftoff and mask).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:18
S68	6	((chemical adj mechanical) and liftoff and mask).clm.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/24 15:18
S69	1329	(GMR with AMR)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 11:46
S70	7	(GMR with AMR with advantages)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 11:48
S71	263	(GMR with AMR) and (liftoff or lift-off or (lift adj off))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 11:49
S72	1222	(liftoff or lift-off or (lift adj off)) and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3) and (magnetic or magnetoresist\$4 or AMR or GMR or MR)	US-PGPUB; USPAT	OR	OFF	2005/07/25 11:51
S73	162	(liftoff or lift-off or (lift adj off)) and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3).clm. and (magnetic or magnetoresist\$4 or AMR or GMR or MR)	US-PGPUB; USPAT	OR	OFF	2005/07/25 11:55
S74	269	((liftoff or lift-off or (lift adj off)) with (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3))	US-PGPUB; USPAT	OR	OFF	2005/07/25 11:54
S75	9	((liftoff or lift-off or (lift adj off)) with (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3))	JPO	OR	OFF	2005/07/25 11:54



S76	75	(liftoff or lift-off or (lift adj off)) with (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3) and (magnetic or magnetoresist\$4 or AMR or GMR or MR)	US-PGPUB; USPAT	OR	OFF	2005/07/25 12:28
S77	612	(216/22).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/07/25 12:28
S78	189	S77 and (CMP or chemical-mechanical or (chemical adj mechanical) or polish\$3)	US-PGPUB; USPAT	OR	OFF	2005/07/25 12:28